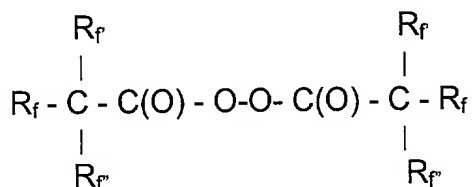


Author	Year	Country	Sample Size	Age Range	Gender	Study Type	Findings
Wang et al.	2008	China	1,000	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Li et al.	2009	China	1,200	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Zhang et al.	2010	China	1,500	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Chen et al.	2011	China	1,800	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Wu et al.	2012	China	2,000	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Yang et al.	2013	China	2,200	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Xu et al.	2014	China	2,500	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Guo et al.	2015	China	2,800	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
He et al.	2016	China	3,000	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Li et al.	2017	China	3,200	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Wang et al.	2018	China	3,500	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Zhang et al.	2019	China	3,800	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Chen et al.	2020	China	4,000	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Wu et al.	2021	China	4,200	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Yang et al.	2022	China	4,500	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Xu et al.	2023	China	4,800	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Guo et al.	2024	China	5,000	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
He et al.	2025	China	5,200	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Li et al.	2026	China	5,500	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Wang et al.	2027	China	5,800	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Zhang et al.	2028	China	6,000	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Chen et al.	2029	China	6,200	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Wu et al.	2030	China	6,500	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Yang et al.	2031	China	6,800	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Xu et al.	2032	China	7,000	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Guo et al.	2033	China	7,200	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
He et al.	2034	China	7,500	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Li et al.	2035	China	7,800	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Wang et al.	2036	China	8,000	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Zhang et al.	2037	China	8,200	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Chen et al.	2038	China	8,500	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Wu et al.	2039	China	8,800	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Yang et al.	2040	China	9,000	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Xu et al.	2041	China	9,200	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Guo et al.	2042	China	9,500	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
He et al.	2043	China	9,800	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.
Li et al.	2044	China	10,000	18-25	Male	Quantitative	High levels of self-esteem and low levels of self-doubt.

are used.

5. (Amended) A polymerization process according to claim 2, wherein at temperatures of the order of -20° - $+25^{\circ}\text{C}$, the perfluorodiacylperoxides of structure (A) of formula:



are used, wherein when R_f is $-\text{CF}_3$, R_f and R_f are C_1 - C_3 linear or branched perfluorooxyalkyl groups.

6. (Amended) A polymerization process according to claim 2, wherein the fluorinated monomers are selected from:

- C_2 - C_8 perfluoroolefins, such as tetrafluoroethylene (TFE), hexafluoropropene (HFP);
- C_2 - C_8 hydrogenated fluoroolefins, such as vinyl fluoride (VF), vinylidene fluoride (VDF), trifluoroethylene, $\text{CH}_2=\text{CH}-\text{R}_f$ perfluoroalkylethylene, wherein R_f is a C_1 - C_6 perfluoroalkyl, hexafluoroisobutene;
- C_2 - C_8 chloro-fluoroolefins, such as chlorotrifluoroethylene (CTFE);
- $\text{CF}_2=\text{CFOR}_f$ (per)fluoroalkylvinylethers (PAVE), wherein R_f is a C_1 - C_6 (per)fluoroalkyl, for example CF_3 , C_2F_5 , C_3F_7 ;
- $\text{CF}_2=\text{CFOX}$ (per)fluoro-oxyalkylvinylethers, wherein X is: a C_1 - C_{12} alkyl, or a C_1 - C_{12} oxyalkyl, or a C_1 - C_{12} (per)fluorooxyalkyl having one or more ether groups;
- perfluorodioxoles, such as 2,2,4-trifluoro-5-trifluoromethoxy-1,3-dioxole (TTD), 2,2-bis-trifluoromethyl-4,5-difluoro-dioxole (PPD);

- sulphonic monomers, such as $\text{CF}_2=\text{CFOCF}_2\text{CF}_2\text{SO}_2\text{F}$;
- fluorinated dienes such as $\text{CF}_2=\text{CFOCF}_2\text{CF}_2\text{CF}=\text{CF}_2$,
 $\text{CF}_2=\text{CFOCCl}_2\text{CF}_2\text{CF}=\text{CF}_2$, $\text{CF}_2=\text{CFOCF}_2\text{OCF}=\text{CF}_2$, $\text{CF}_2=\text{CFOCF}_2\text{OCCl}=\text{CF}_2$,
 $\text{CF}_2=\text{CFOC}(\text{CF}_3)_2\text{OCF}=\text{CF}_2$.

7. (Amended) A polymerization process according to claim 2, wherein the perfluorodiacylperoxide initiator is fed in a continuous way or by a single addition at the starting of the polymerization.

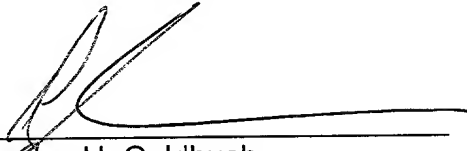
8. (Amended) A polymerization process according to claim 2, wherein the amount of perfluorodiacylperoxide initiator is in the range 0.0001% - 5% by moles with respect to the amount of the fed monomers.

REMARKS

Claims 1-8 are pending in this application. By this Amendment, claims 4-8 are amended to correct the multiple dependencies thereof and to place this application into better condition for examination. No new matter has been added.

In the event that there are any fees due with respect to the filing of this paper,
please charge Deposit Account No. 01-2300.

Respectfully submitted,



Douglas H. Goldhush
Registration No. 33,125

Customer No. 004372

ARENT FOX KINTNER PLOTKIN & KAHN, PLLC

1050 Connecticut Avenue, N.W.,

Suite 400

Washington, D.C. 20036-5339

Tel: (202) 857-6000

Fax: (202) 638-4810

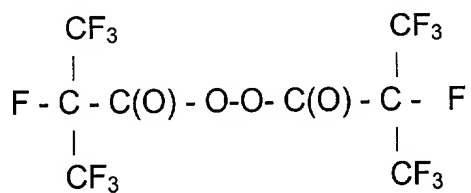
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Enclosures: Marked-up Copy of Amended Claims

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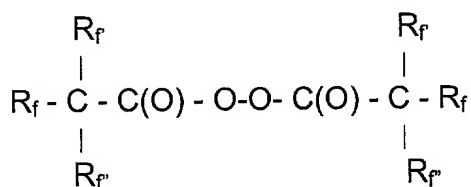
MARKED-UP COPY OF AMENDED CLAIMS
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4. (Amended) A polymerization process according to [claims 2-3] claim 2, wherein at temperatures of the order of 50° - 80°C, the perfluorodiacylperoxides of structure (C) or the compound of structure (A) having the formula:



are used.

5. (Amended) A polymerization process according to [claims 2-3] claim 2, wherein at temperatures of the order of -20° - +25°C, the perfluorodiacylperoxides of structure (A) of formula:



are used, wherein when R_f is $-\text{CF}_3$, R_f and $\text{R}_{f'}$ are C_1 - C_3 linear or branched perfluorooxyalkyl groups.

6. (Amended) A polymerization process according to [claims 2-5] claim 2, wherein the fluorinated monomers are selected from:

- C_2 - C_8 perfluoroolefins, such as tetrafluoroethylene (TFE), hexafluoropropene (HFP);

- C₂-C₈ hydrogenated fluoroolefins, such as vinyl fluoride (VF), vinylidene fluoride (VDF), trifluoroethylene, CH₂=CH-R_f perfluoroalkylethylene, wherein R_f is a C₁-C₆ perfluoroalkyl, hexafluoroisobutene;
- C₂-C₈ chloro-fluoroolefins, such as chlorotrifluoroethylene (CTFE);
- CF₂=CFOR_f (per)fluoroalkylvinylethers (PAVE), wherein R_f is a C₁-C₆ (per)fluoroalkyl, for example CF₃, C₂F₅, C₃F₇;
- CF₂=CFOX (per)fluoro-oxyalkylvinylethers, wherein X is: a C₁-C₁₂ alkyl, or a C₁-C₁₂ oxyalkyl, or a C₁-C₁₂ (per)fluoroalkoxyalkyl having one or more ether groups;
- perfluorodioxoles, such as 2,2,4-trifluoro-5-trifluoromethoxy-1,3-dioxole (TTD), 2,2-bis-trifluoromethyl-4,5-difluoro-dioxole (PPD);
- sulphonic monomers, such as CF₂=CFOCF₂CF₂SO₂F;
- fluorinated dienes such as CF₂=CFOCF₂CF₂CF=CF₂,
CF₂=CFOCCl₂CF₂CF=CF₂, CF₂=CFOCF₂OCF=CF₂, CF₂=CFOCF₂OCCI=CF₂,
CF₂=CFOC(CF₃)₂OCF=CF₂.

7. (Amended) A polymerization process according to [claims 2-6] claim 2, wherein the perfluorodiacylperoxide initiator is fed in a continuous way or by a single addition at the starting of the polymerization.

8. (Amended) A polymerization process according to [claims 2-7] claim 2, wherein the amount of perfluorodiacylperoxide initiator is in the range 0.0001% - 5% by moles with respect to the amount of the fed monomers.